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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/563,450	04/14/2006	Adolf Kuehnle	283349US0PCT	8096
,	7590 07/30/200 AK, MCCLELLAND,	EXAMINER		
1940 DUKE STREET			PATEL, REEMA	
ALEXANDRIA, VA 22314			ARŢ UNIT	PAPER NUMBER
		2812		
	-			
			NOTIFICATION DATE	DELIVERY MODE
•	,		07/30/2007	ELECTRONIC

# Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

patentdocket@oblon.com oblonpat@oblon.com jgardner@oblon.com

		TH				
	Application No.	Applicant(s)				
Office Assistant Commencer	10/563,450	KUEHNLE ET AL.				
Office Action Summary	Examiner	Art Unit				
	Reema Patel	2812				
The MAILING DATE of this communication a Period for Reply	ppears on the cover sheet w	rith the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING  - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory perions are the provision of the provision of the period for reply will, by state the provision of th	DATE OF THIS COMMUNI 1.136(a). In no event, however, may a not will apply and will expire SIX (6) MOI nute, cause the application to become A	CATION. reply be timely filed  NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).				
Status		·.				
1)⊠ Responsive to communication(s) filed on 03	January 2006					
3) Since this application is in condition for allow						
Disposition of Claims						
4)⊠ Claim(s) <u>1-11</u> is/are pending in the application	on.					
4a) Of the above claim(s) is/are withdi		•				
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-11</u> is/are rejected.		· · · · · · · · · · · · · · · · · · ·				
7) Claim(s) is/are objected to.		·				
8) Claim(s) are subject to restriction and	l/or election requirement.					
Application Papers						
9)☐ The specification is objected to by the Exami	ner.					
10) The drawing(s) filed on is/are: a) a	ccepted or b)  objected to	by the Examiner.				
Applicant may not request that any objection to the	ne drawing(s) be held in abeya	nce. See 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the corre	ection is required if the drawing	g(s) is objected to. See 37 CFR 1.121(d).				
11)☐ The oath or declaration is objected to by the	Examiner. Note the attache	d Office Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12)⊠ Acknowledgment is made of a claim for foreig	n priority under 35 U.S.C.	8 119(a)-(d) or (f)				
a)⊠ All b)□ Some * c)□ None of:	gir priority under do d.d.d.	3 1 10(d) (d) 01 (i).				
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority docume		Application No.				
3. Copies of the certified copies of the pr		· · · · · · · · · · · · · · · · · · ·				
application from the International Bure						
* See the attached detailed Office action for a li	st of the certified copies not	received.				
•						
Attachment(s)	•					
1) Notice of References Cited (PTO-892)	4) Interview	Summary (PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(	s)/Mail Date				
3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 4/3/06,9/11/06.	5) Motice of l	Informal Patent Application .				

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#### **DETAILED ACTION**

## **Priority**

1. Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

## Information Disclosure Statement

2. The information disclosure statements (IDS) were submitted on 4/3/06 and 9/11/06. The submission is in compliance with the provisions of 37 CFR 1.97. Accordingly, the information disclosure statements have been considered by the examiner.

# Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 4. Claims 1, 3, and 8-11 are rejected under 35 U.S.C. 102(b) as being anticipated by Huang et al. ("Structure and Interaction of Organic/Inorganic Hybrid Nanocomposites for Microelectronic Applications").

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5. Regarding claim 1, Huang et al. discloses a process for producing low-k dielectric

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films which comprises using incompletely condensed polyhedral oligomeric

silsesquioxanes of the formula [R<sub>a</sub>X<sub>b</sub>SiO<sub>1,5</sub>)<sub>m</sub>(R<sub>c</sub>Y<sub>d</sub>SiO)<sub>n</sub>] (Figure 1(a)).

6. Regarding claim 3, Huang et al. discloses the incompletely condensed polyhedral

oligomeric silesquioxane contains not more than three hydroxyl groups as type Y

substituents (Figure 1(a)).

7. Regarding claim 8-11, Huang et al. discloses the low-k dielectric film is produced

by means of spin coating and subsequent calcining (page 3679, col 1, lines 13-22; page

3678, col 1, lines 1-6) and has a k value of less than or equal to 2.3 (page 3682, col 2,

lines 30-33).

8. Claims 1-7 are rejected under 35 U.S.C. 102(e) as being anticipated by Jost et

al. (U.S. 2005/0010012 A1).

9. Regarding claim 1, Jost et al. discloses a process for producing low-k dielectric

films ([0031]-[0032]; [0014]) which comprises using incompletely condensed polyhedral

oligomeric silsesquixanes of the formula  $[(R_aX_bSiO_{1.5})_m(R_cY_dSiO)_n]$  ([0015]-[0016]).

10. Regarding claim 2, Jost et al. discloses using incompletely condensed polyhedral

oligometric silsesquixanes of the formula  $[(R_aSiO_{1.5})_m(R_cY_dSiO)_n]$  ([0015]-[0016]).

11. Regarding claim 3, Jost et al. the incompletely condensed polyhedral oligomeric

silesquioxane contains not more than three hydroxyl groups as type Y substituents

([0015]).

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12. Regarding claims 4-5, Jost et al. discloses the incompletely condensed polyhedral oligomeric silsesquioxanes are reacted with a tetralkoxysilanes ([0016]-[0018]).

13. Regarding claims 6-7, Jost et al. discloses the molar ratio of the incompletely condensed polyhedral oligomeric silsesquioxanes to the coreactant capable of hydrolytic condensation is 2:1 ([0021]).

### Conclusion

14. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Jost et al. (WO 03/042223 A1) and Lichtenhan et al. (2003/0055193 A1) disclose condensing incompletely condensed polyhedral oligomeric silsesquioxanes.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Reema Patel whose telephone number is 571-270-1436. The examiner can normally be reached on M-F, 8:00-4:30 EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Lebentritt can be reached on 571-272-1873. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

RSP 7/19/07 SCOTT B. GEYER
PRIMARY EXAMINER

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